

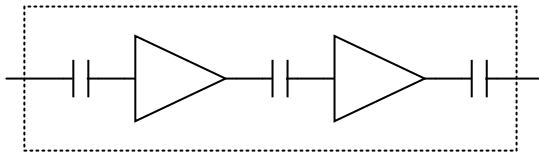
Product Overview

The ASA6011 is a GaN MMIC two-stage power amplifier designed for X-band applications. The amplifier provides 21 dB of power gain, 34.5 dBm of saturated power and 44.8% PAE from a +25 V supply voltage. All data is measured with the chip in a 50 Ohm test fixture connected via two 0.025 mm (1 mil) diameter bondwires of minimal length 0.51 mm (20 mil).

Key Features

1. Integrated DC blocking at RF input/output
2. Frequency Range: 8.5 GHz to 10 GHz
3. Power Gain: 20.5 dB
4. PAE: 45%
5. Saturated Output Power: +34.5 dBm
6. 50 Ohm Matched Input/output
7. Die Size: 1.6 x 2.4 x 0.1 mm

Functional Block Diagram



Applications

1. General Communication Applications
2. VSAT
3. Point to Point Radios

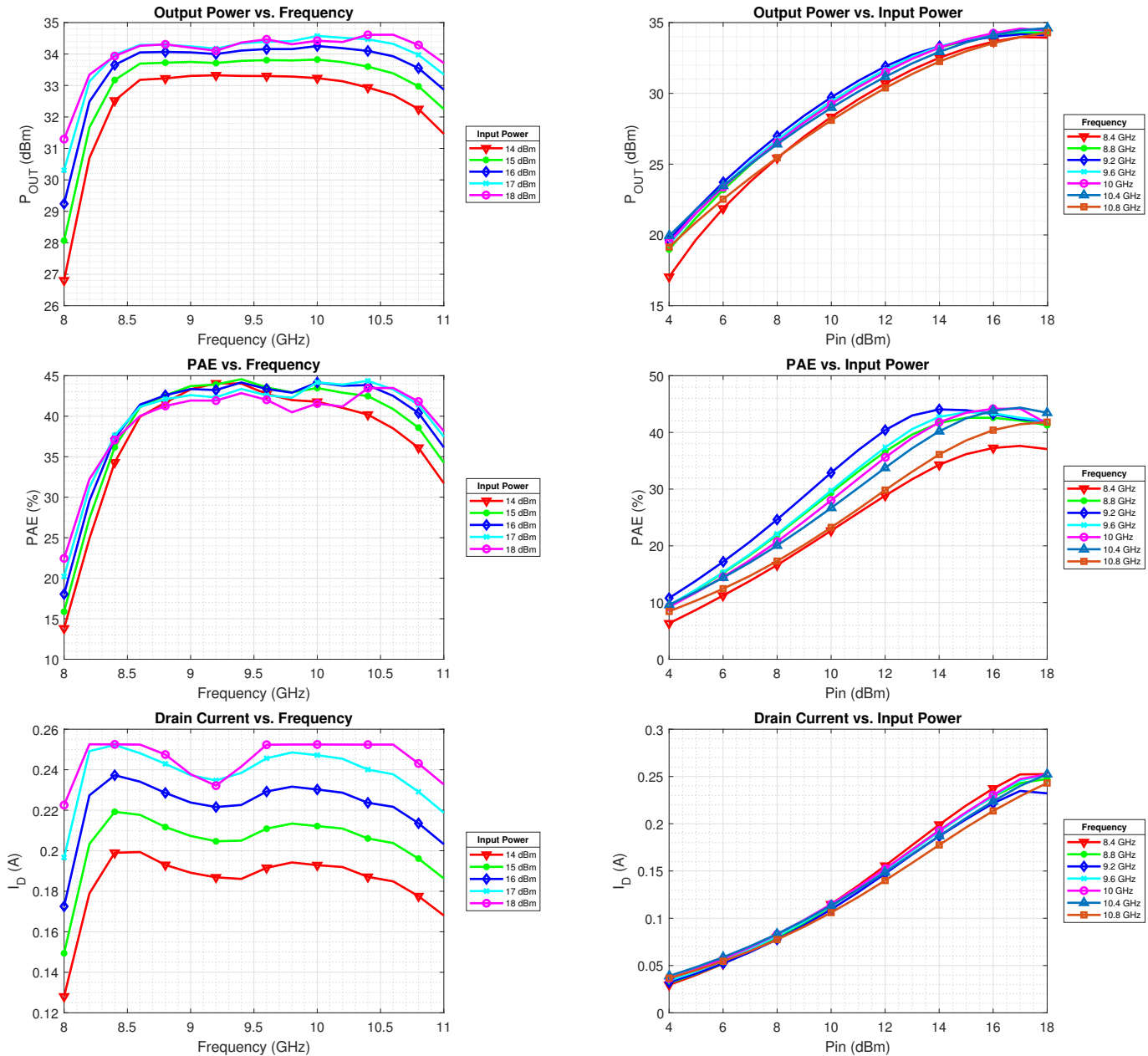
Electrical Specifications

Parameter	Min.	Typ.	Max.	Units
Frequency Range	-	8.5-10	-	GHz
Power Gain	19.5	20	20.5	dB
Small Signal Gain (IDQ = 99 mA)	-	27	-	dB
Input Return Loss	-	12	-	dB
Power Added Efficiency (PAE)	42	43	45	%
Saturated Output Power	33.5	34	34.5	dBm
Supply Current (with RF)	220	240	260	mA

Test conditions unless otherwise noted: Tcase=15°C, VDD=25 V, VGG=-3.2 V, IDQ=99 mA, Z0=50 Ω, Pin=14 dBm
Tcase is Cold Plate temperature, and Base Plate temperature (TBP) is 85°C.

Performance Plots – Large Signal

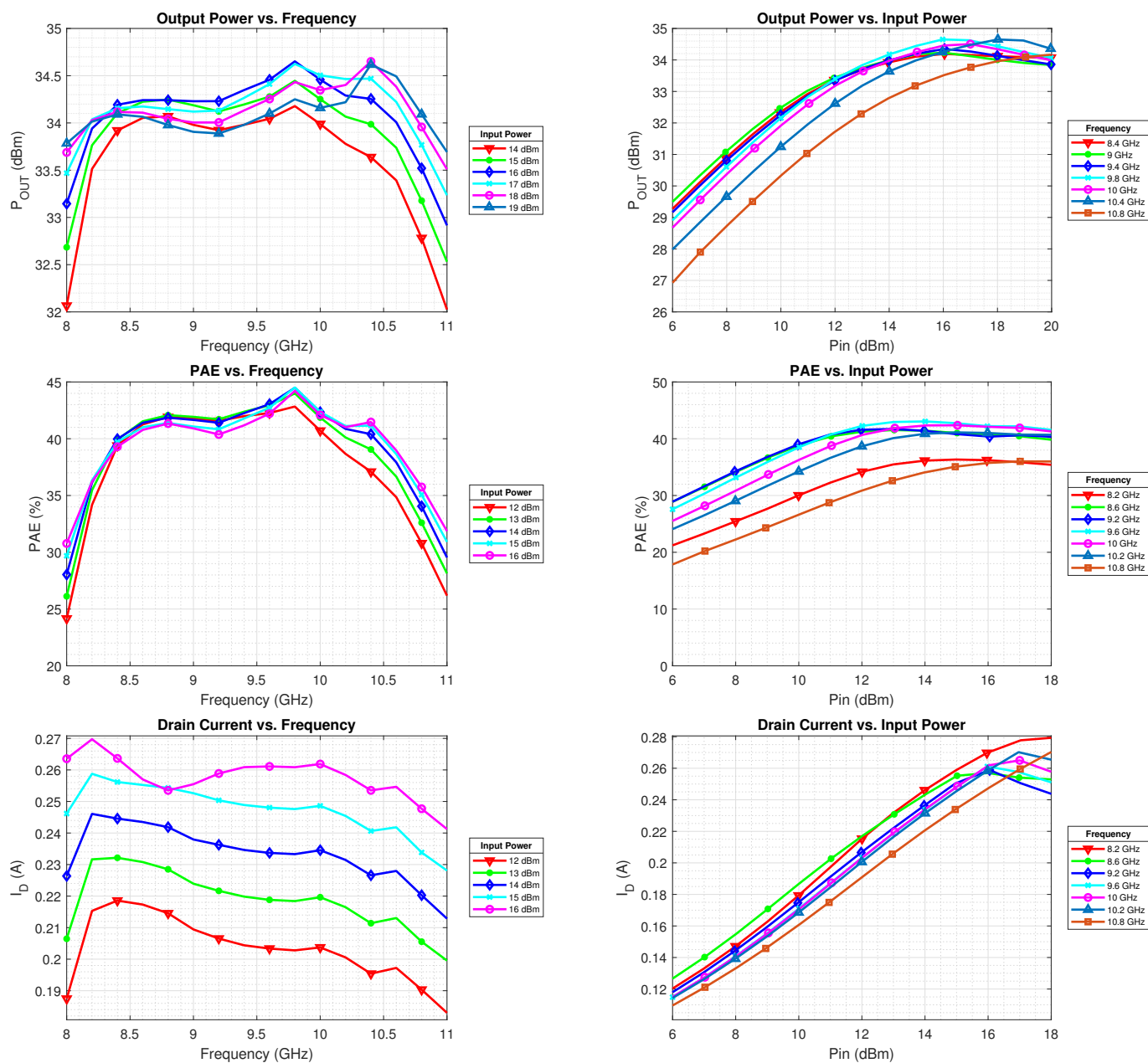
Test conditions unless otherwise noted: $V_{DD}=25\text{ V}$, $V_{GG}=-3.5\text{ V}$, $I_{DQ}=2\text{ mA}$, $P_{in}=16\text{ dBm}$, $T_{case}=15^\circ\text{C}$, CW



Performance Plots – Large Signal

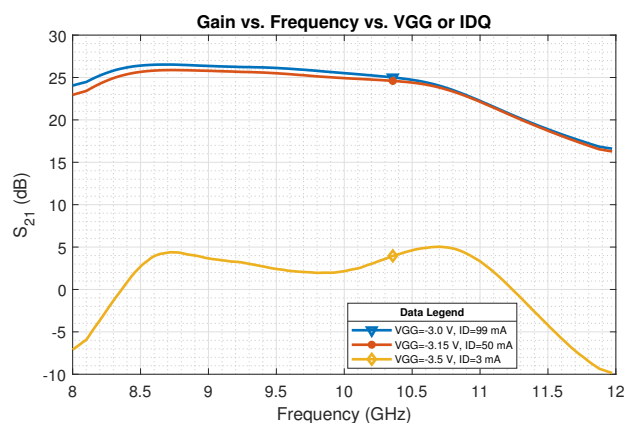
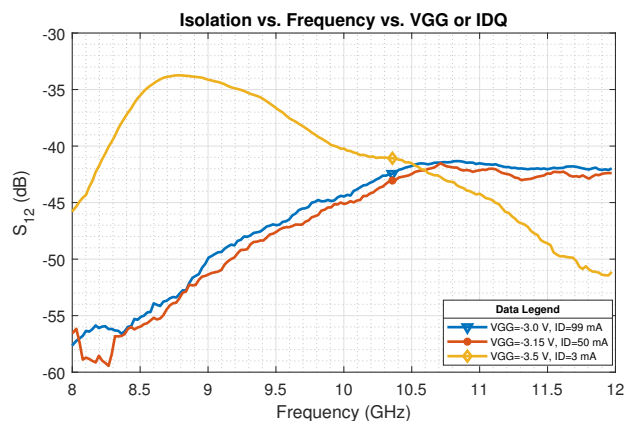
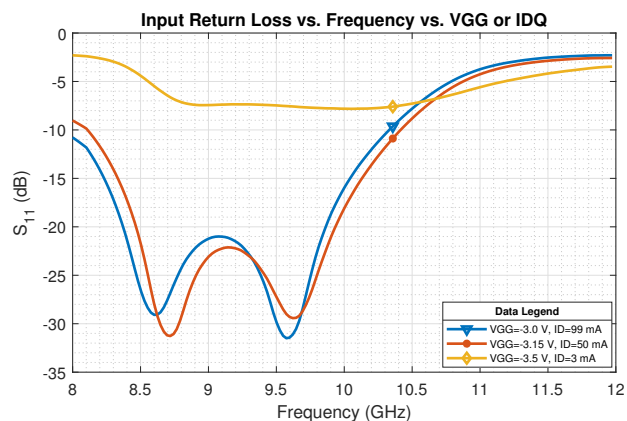
Test conditions unless otherwise noted: $V_{DD}=25\text{ V}$, $V_{GG}=-3.2\text{ V}$, $I_{DQ}=99\text{ mA}$, $P_{in}=14\text{ dBm}$, $T_{case}=15$

$^{\circ}\text{C}$, CW

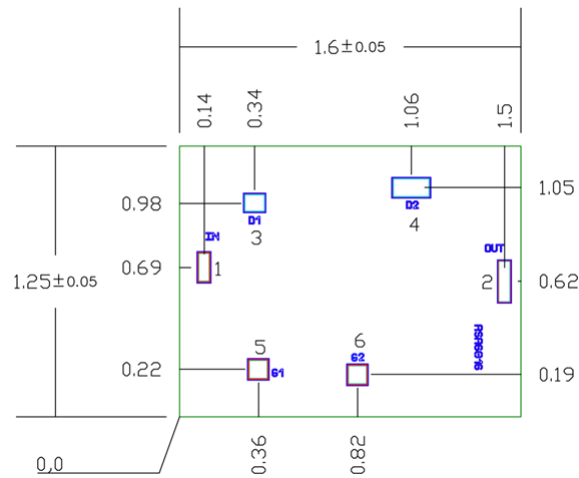


Performance Plots – Small Signal

Test conditions unless otherwise noted: VDD=25 V, Tcase=15 °C



Mechanical Information



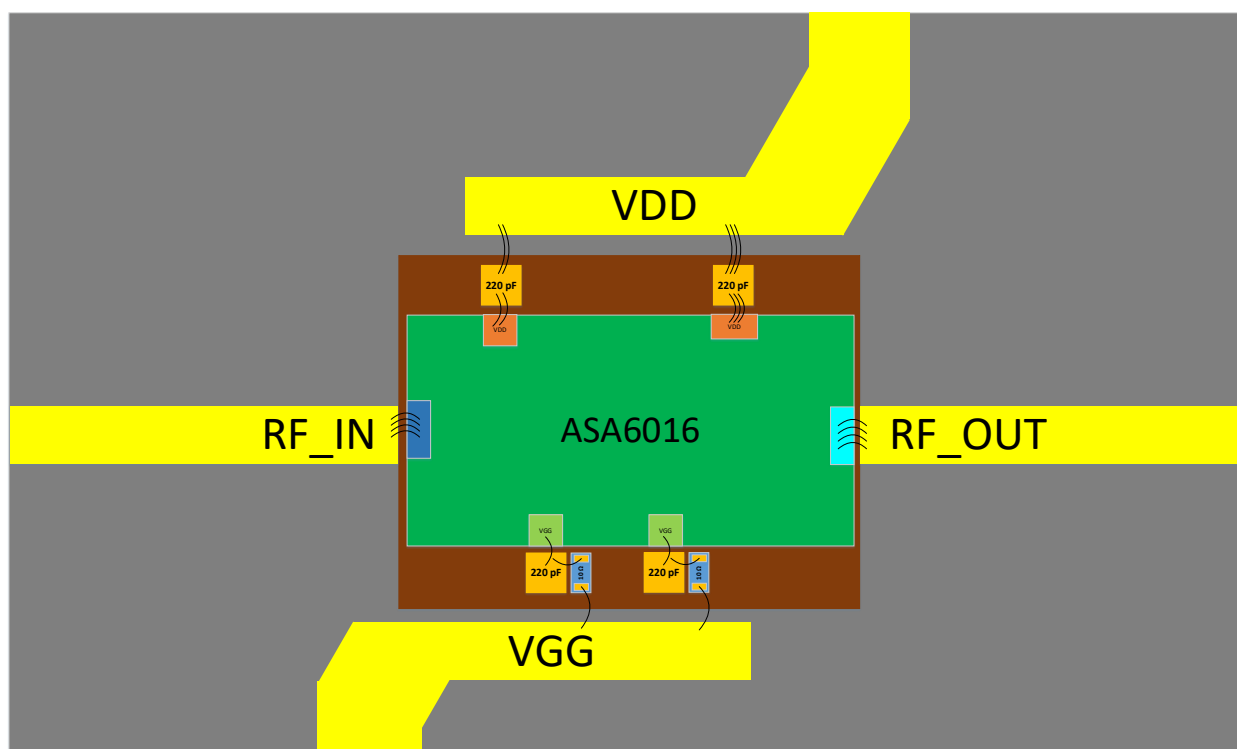
NOTES:

1. ALL DIMENSIONS ARE IN MILLIMETERS
2. CHIP SIZE = 1.6 mm × 2.4 mm (DICING STREET INCLUDED) ± 0.05 mm
3. RF pads (1) = 0.145 × 0.065 mm
4. RF pads (2) = 0.2 × 0.065 mm
5. DC pads (3) = 0.103 × 0.91 mm
6. DC pads (4) = 0.180 × 0.096 mm
7. DC pads (5,6) = 0.1 × 0.1 mm
8. BACKSIDE METALLIZATION: GOLD
9. BACKSIDE METAL IS GROUND
10. BOND PAD METALIZATION: GOLD
11. NO CONNECTION REQUIRED FOR UNLABELED BOND PADS
12. OVERALL DIE SIZE ±50 μm

Bond Pad Description

1	RF-IN	This pad is AC coupled and matched to 50 Ohms.
2	RF-OUT	This pad is AC coupled and matched to 50 Ohms.
3,4	VDD	Positive Supply Voltage for the amplifier. External bypass capacitors of 220 pF are required.
5,6	VGG	Negative Supply Voltage for the amplifier.

Assembly Diagram



Assembly Notes

Component Placement and Adhesive Attachment Assembly Notes:

1. Use vacuum collet to pick up the die.
2. The force should be controlled during placement and mounting specially no force should be applied to air bridges.

Reflow process assembly notes:

1. Use CMC or MoCu carrier to decrease thermal expansion mechanical stress
2. Use AuSn (80/20) solder and limit exposure to temperatures above 300 °C to 3-4 minutes, maximum.
3. An alloy station or conveyor furnace with reducing atmosphere should be used.
4. Do not use any kind of flux.
5. Devices must be stored in a dry nitrogen atmosphere.
6. Use Au bond wire.

Contact Information

For the latest specifications, additional product information:

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